
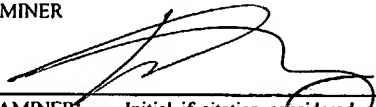


INFORMATION DISCLOSURE STATEMENT <i>(Use several sheets if necessary)</i>				ATTY. DOCKET NO.		SERIAL NO.	
				2000U042D1.US-CON1		Unassigned	
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				Simon Mawson et al.			
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U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
WKE	AA	5,317,036	05/13/1994	Brady, III et al.	523	223	
WKE	AB	5,693,727	12/02/1997	Goode et al.	526	86	
WKE	AC	6,069,213	05/30/2000	Nemzek, et al.	502	117	
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	PUBL. DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION
							YES NO
WKE	AJ	EP 0593083 A	04/20/1994	Europe			
WKE	AK	WO 97/46599	12/11/1997	Patent Cooperation Treaty			
WKE	AL	JP 10-330412	12/15/1998	Japan			X
WKE	AN	97116451.7	03/24/1999	China			X
OTHER DISCLOSURES (Including Author, Title, Date, Pertinent Pages of Publication, Etc.)							
WKE	AN	Chu et al., "Effect of Hydrogen on Ethylene Polymerization with In-Situ Supported Metallocene Catalysts", Institute for Polymer Research, Dept. of Chem. Eng., University of Waterloo, Waterloo, Ontario N2L 3G1, Canada					
WKE	AO	Chu, et al., "Polymerization Mechanism for In-Situ Supported Metallocene Catalysts", Institute for Polymer Research, Dept. of Chem. Eng., University of Waterloo, Waterloo, Ontario N2L 3G1, Canada					
EXAMINER				DATE CONSIDERED			
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/	BA	/	/	/	/	/	/
/	BB	/	/	/	/	/	/
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	PUBL. DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
Wk	BC	EP 0965601 A	12/22/1999	Europe	/	/	/ /
/	BD	/	/	/	/	/	/ /
/	BE	/	/	/	/	/	/ /
OTHER DISCLOSURES (Including Author, Title, Date, Pertinent Pages of Publication, Etc.)							
Wk	BF	Chu, et al., "Variation of Molecular Weight Distribution (MWD) and Short Chain Branching Distribution (SCBD) of Ethylene/1-Hexene Copolymers Produced with Different IN-Situ Supported Metallocene Catalysts", Institute for Polymer Research, Dept. of Chem. Eng., University of Waterloo, Waterloo, Ontario N2L 3G1, Canada					
/	BG	Soares, et al., "Environmental Stress Cracking Resistance of Polyethylene: Use Of Crystaf and Sec to Establish Structure-Property Relationships", Institute for Polymer Research, Dept. of Chem. Eng., University of Waterloo, Waterloo, Ontario N2L 3G1, Canada					
/	BH	J.B.P. Soares and J.D. Kim, "Copolymerization of Ethylene and α -Olefins With Combined Metallocene Catalysts. I. A Formal Criterion for Molecular Weight Bimodality", Institute for Polymer Research, Department of Chemical Engineering, University of Waterloo, Waterloo, Ontario, Canada N2L 3G1					
/	BI	J.D. Kim and J.B.P. Soares, "Copolymerization of Ethylene and α -Olefins With Combined Metallocene Catalysts. II. Mathematical Modelling of Polymerization with Single Metallocene Catalysts", Institute for Polymer Research, Department of Chemical Engineering, University of Waterloo, Waterloo, Ontario, Canada N2L 3G1					
Wk	BJ	J.D. Kim and J.B.P. Soares, "Copolymerization of Ethylene and α -Olefins With Combined Metallocene Catalysts. III. Production of Polyolefins with Tailored Microstructure", Institute for Polymer Research, Department of Chemical Engineering, University of Waterloo, Waterloo, Ontario, Canada N2L 3G1					
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